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[Title of the invention] SEMICONDUCTOR DEVICE WITH  
Kr-CONTAINING SILICON OXIDE FILM INTEGRATED THEREINTO,  
AND MANUFACTURING METHOD OF THE SILICON OXIDE FILM

[Number of claims] 7

[Inventor]

[Address] 1-17-301, Komegabukuro 2-chome, Aoba-ku,  
Sendai-shi, Miyagi

[Name] Tadahiro OHMI

[Applicant for patent]

[Identification number] 000205041

[Name] Tadahiro OHMI

[Attached documents]

[Document] Specification 1

[Document] Drawing 1

[Document] Abstract 1